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	Application No.	Applicant(s)	
	10/669,378	LIM, BYOUNG HO	
Notice of Allowability	Examiner	Art Unit	
•	Tai Duong	2871	
All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.  1. ☑ This communication is responsive to Amendment 05/09/05.  2. ☑ The allowed claim(s) is/are 1 and 3-15.  3. ☑ The drawings filed on 25 September 2003 are accepted by the Examiner.  4. ☑ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).  a) ☐ All b) ☐ Some* c) ☑ None of the:  1. ☑ Certified copies of the priority documents have been received.  2. ☐ Certified copies of the priority documents have been received in Application No  3. ☐ Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)).  **Certified copies not received:  Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.  THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.  5. ☐ A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.  (a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached  1) ☐ heretor or 2) ☐ to Paper No./Mail Date  (b) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached  1) ☐ heretor or 2) ☐ to Paper No./Mail Date  (b) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached  1) ☐			
Attachment(s)  1. Notice of References Cited (PTO-892)  2. Notice of Draftperson's Patent Drawing Review (PTO-948)  3. Information Disclosure Statements (PTO-1449 or PTO/SB/O Paper No./Mail Date  4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. Interview Summary Paper No./Mail Dat 08), 7. Examiner's Amendr	te	

Application/Control Number: 10/669,378

Art Unit: 2871

## **REASONS FOR ALLOWANCE**

Acknowledgment is made of applicant's claim for foreign priority based on an application filed in Korea on 10/05/02. It is noted, however, that applicant has not filed a certified copy of the Korean application as required by 35 U.S.C. 119(b).

The following is an examiner's statement of reasons for allowance:

Amended claim 1 is allowed over the prior art of record because it includes the allowable feature of claim 2, as set forth in the last Office action. Claims 3-8 are also allowed since they depend on the allowed claim 1.

Claims 9-13 stand allowed for the same reasons set forth in the last Office action.

Claim 14 is allowed over the prior art of record because none of the prior art discloses or suggests a LCD panel having the combination of the features "a plurality of pixel electrodes receiving data signals having different polarities from each other", " a semiconductor layer formed along a direction of each of the data lines at a lower part of the data lines to extend past edge portions of the data lines", and "a plurality of light-shielding patterns formed along the direction of the data lines to extend past edge portions of the data lines to extend past edge portions of the data lines".

Claim 15 is allowed over the prior art of record because none of the prior art discloses or suggests a method of fabricating a LCD panel having the combination of the steps "forming a gate electrode, a gate line, and individual first and second light-shielding patterns on a substrate", "forming a semiconductor layer on the gate insulating film to partially overlap the individual first and second light-shielding patterns", and

"forming a data line on the gate insulating film to partially overlap the individual first and second light-shielding patterns and the semiconductor layer".

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication should be directed to Tai Duong at telephone number (571) 272-2291.

The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

TVD

06/05